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Application No. 09/914,255

TITLE OF THE INVENTION

BIDIMENSIONAL DETECTOR OF IONIZING RADIATION
AND MANUFACTURING PROCESS FOR THIS DETECTOR.



DESCRIPTION BACKGROUND OF THE INVENTION

TECHNICAL DOMAIN: Field of the Invention

The present invention concerns a bidimensional detector of ionizing radiation as well as a manufacturing process for this detector.

The ionizing radiations which can be detected by the invention can particularly consist of ~~contain~~ X-rays, gamma photons ~~gammas~~, protons, neutrons or muons.

The detector, subject of the current invention, is capable of converting incident ionizing radiation into ~~other~~ particles, which are themselves ionizing (electrons for example) and are easier to work with than the incident ionizing radiation.

In particular, the invention may be used in the following sectors:

- instantaneous radiography of highly absorbing and/or voluminous objects,
- ultra rapid cineradiography of mechanical mobiles,
- positioning of patients in radiotherapy,
- neutronography,
- protonography,
- medical and biological imagery (tomographies by emission of positrons), and
- imagery by coded apertures to inspect voluminous objects with low radioactivity or suspicious parcels in a passive or quasi-passive manner.

~~PREVIOUS STATE OF THE ART~~ discussion of the Background

The ~~b~~ Bidimensional detectors of ionizing radiation are already known and consist of ~~detector's which are already exist~~ feature plates made of a heavy metal such as lead, or, more precisely some other metal, of a material with a high cross-section factor, ~~that is, a large~~ surface of interaction with ~~the~~ an incident ionizing radiation.

For example, it is common to use a metal with an atomic number (Z) greater than or equal to 73 to detect X- or gamma-ray photons and a metal with an atomic number (Z) generally less than 14 or greater than 90 to detect neutrons.

Other materials, such as Gadolinium (Z= 64) can also be used to detect neutrons.

Holes are drilled in the metal plates using either chemical or electrochemical ~~procedures~~ etching. The plates are ~~isolated~~ electrically insulated from each other if

necessary, that is, when plate thickness is equal to, or greater than, a few hundred micrometers.

The holes are ~~then~~ filled with an ionizable gas.

A high-energy incident photon (X- or gamma-) then ~~results in the release of~~ generates at least one electron in one of the detector plates, either by Compton effect or pair-creation effect.

The incident X- or gamma-~~ray~~ photon causes the released electrons to move rapidly with a kinetic energy approximately equal to that of the incident photon. The electron then rapidly ionizes some ~~gas-molecules~~ of the gas contained in one of the holes which the electron reaches and, generally, passes through. Slow secondary electrons which are removed from these molecules due to the ionization of the molecules, are routed along this hole and ~~then~~ collected by means of ~~an a bias~~ electric polarization field (bias), also referred to as a drift field. The slow secondary electrons are then detected in, for example, an ionization chamber or in a proportional avalanche chamber.

Such bidimensional detectors are for example described in documents [1], [2], [3], [6], and [7] which, like ~~all the~~ other documents referenced hereafter, are listed at the end of the present description.

The decision to use a whole-detection system can be explained by the fact that such a systems offers a very high degree of spatial resolution and offers a high level of performance, subject to the holes being perfectly formed and sufficiently ~~large~~ wide.

The holes are created by means of chemical etching. This procedure is preferable to waterjet cutting which suffers from the disadvantage of generating a frontal shock when the waterjet is ~~opened to begin~~ turned on in the beginning of the drilling of a the holes.

This frontal shock chips the material in which the holes are to be cut, which splits the material and makes it unfit for use.

However chemical etching is an expensive and slow process.

Moreover, the quantity of secondary electrons collected, and by extension, the performance levels of hole-system detectors are limited since only between 10% to 30% of the secondary electrons created in the course of each gas ionization are collected.

This can be explained by the fact that chemical etching does not create holes whose interior walls are perfectly cylindrical, that is, it cuts bottlenecks in the holes which in turn causes the electric field line to be deformed and reduces the useful diameter of the holes.

Thus, the performance levels of hole-system detectors are low.

~~PRESENTATION OF THE INVENTION~~SUMMARY OF THE INVENTION

The objective of the present invention is ~~to remedy~~a detector that remedies the aforementioned inconveniences of hole-based detector (that is, expensive and low performance levels). The present invention proposes to meet this objective, in part, by using slits instead of holes.

To reformulate the above in a more precise manner; the objective of the present invention is ~~an~~ bidimensional ionizing radiation detector ~~for the~~ intended for use with incident radiation consisting of primary particles whose energies are greater than, or equal to 100 keV. Furthermore, the detector includes a block featuring a converting material capable of releasing secondary particles by interaction with the incident ionizing radiation, whereby the thickness of the block is at least equal to one-tenth of the mean free path traveled by the primary particles of the incident radiation in the material. The detector is characterized by the fact that it has parallel slits running across the block, which are filled with a fluid capable of interacting with the secondary particles to produce tertiary particles equal in intensity and position to the incident radiation whereby the block is positioned in such a manner as to ensure that the incident radiation comes in on a first face where the slits terminate.

These slits divide the block into strips.

The detector (~~subject of the invention~~) is far less expensive to manufacture than the hole-system detectors previously mentioned.

Moreover, it is ~~reasonable to expect that~~ the detector's level of collection performance and spatial resolution ~~will be~~ are liable to be far better ~~than~~ than the hole-based system.

The detector (~~subject of the invention~~) is also easy to manufacture, and offers a far ~~bigger~~ very important useful detection surface.

Under a first specific manufacturing mode, the slits of the detector (~~subject of the invention~~) are perpendicular to the first block face.

Under a second specific manufacturing mode, the slits planes create an angle of between 1 ° to 5 ° with a line perpendicular to the first block face.

Under a specific manufacturing mode of the detector (~~subject to the invention~~), the fluid in the slits may be ionized by secondary particles (for example, energetic electrons produced by Compton effect), thereby causing the fluid to produce electrons by ionization which may be considered tertiary particles. Furthermore, the detector includes the technology required to create an electric field capable of extracting these electrons from the block.

To this end, an ionizable gas is used, for example.

The detector may also ~~feature the necessary technology to analyze~~ the extracted electrons.

The ~~analysis technology feature of the detector~~ may include an avalanche gas amplifier, capable of producing electron avalanches from the block-extracted electrons.

5 In this case, an ionizable gas may be used, capable of converting the electron avalanches into visible or ultraviolet radiation, and the technology required to analyze visible or ultraviolet radiation may be integrated into the detector (~~subject of the invention~~).

The ~~detection technology~~ detector may include a camera capable of detecting the visible or ultraviolet radiation, or a matrix of amorphous silicon photodiodes placed against
10 the avalanche gas amplifier.

Under a first specific manufacturing mode of the invention, the material ~~is~~ includes an electrical conductor, and the block consists of stacked layers of this material, whereby these layers alternate with electrically insulating layers. Under this first version, the stack begins with a layer of conducting material on the first face of the block, and ends with a layer of
15 conducting material on the second face of the block, located opposite the first face, and on which the slits terminate. The detector (~~object of the invention~~) also includes ~~offers the necessary technology to carry the~~ aforementioned conducting layers connected to electric voltage ~~increasing that increases~~ from the first face to the second face in order to create an electric field.

20 The layer of material on the second block face can be blackened out in order to avoid parasitic light reflections, in particular, ultraviolet.

Under a second specific manufacturing mode for the invention, the material includes an electric insulator (or offers high electrical resistivity) and the block consists of stacked layers of this material or alternatively, is a single mass of this material. Moreover,
25 the block includes first and second layers or grills which are electrical conductors and are located on the first block face and second block face respectively, whereby the second block face is opposite the first face and on which the slits terminate. ~~The~~ An electric field is created by applying an electric voltage to the first layer or grill and a different electric voltage to the second layer of grill which is ~~superior to~~ greater than the first voltage, thereby creating a drift
30 current, from which the tertiary particles (ionization electrons) created by ionization of the fluid, may be extracted.

Under another specific manufacturing mode for the invention, the block ~~is~~ includes a stack of strips made from an isolating (or highly resistive) converting material, and separated from each other by spacers chosen so as to define the parallel block slits. Furthermore, under

this option, the block includes first and second layers or grills which are electrical conductors and are located on the first block face and second block face respectively, whereby the second block face is located opposite the first face and on which the slits terminate. ~~The~~ An electric field is created by applying an electric voltage to the first layer or grill and a different electric voltage to the second layer of grill which is ~~superior to~~ greater than the first voltage.

The present invention also concerns the manufacturing process for the detector
(~~subject to the invention~~).

Under the premises of this manufacturing process, the block is firstly created, after which the slits are created by choosing one of the following three techniques:

- waterjet cutting,
- electrical discharge machining, or,
- roll-out stretch wire.

Under a specific implementation mode for the procedure (~~subject of the invention~~), applicable for the manufacturing of the detector and compatible with the aforementioned first and second specific manufacturing modes (utilization of an electrical conducting material or utilization of an insulating/highly resistive material), the layers which are used are stacked against each other.

Before creating the slits, a guide hole may be created in the block, which will be used as a basis to create the slits.

SHORT BRIEF DESCRIPTION OF THE DRAWINGS

The present invention will be easier to understand from the following manufacturing ~~samples~~ examples, given by way of indication and in no way limiting. Reference is made to the following annexed drawings:

- ——— Figure 1 is a schematic perspective view of specific manufacturing mode according to a possible embodiment of the detector (~~subject of the invention~~),
- ——— Figure 2 is a schematic transversal sectional view of an embodiment of the detector of ~~Figure~~ Figure 1, from a ~~Plan~~ plane P, shown on the sectional view,
- ——— Figure 3 is a schematic perspective view of ~~a~~ another detector embodiment designed in accordance with the invention,
- ——— Figure 4 is a schematic and partial transversal sectional view of another detector embodiment designed in accordance with the invention
- ——— Figure 5 is a block diagram of another detector embodiment designed in accordance with the invention, and

Figure 6 is a block diagram of a possible variation of the detector embodiment mentioned in ~~Figure~~ Figure 2.

~~DETAILED PRESENTATION OF SPECIFIC MANUFACTURING MODES OF THE~~
~~DETECTOR. DESCRIPTION OF THE PREFERRED EMBODIMENTS~~

The bidimensional detector of incident ionizing ~~for~~ radiation having an energies greater than, or equal to, 100keV (as per the precepts of the invention), an embodiment of which is schematically shown in figure Figure 1, ~~consists of~~ comprises a block (2) formed from a converting material, offering a high interaction ~~surface area~~ cross section with respect to the incoming ionizing radiation.

In the case of ~~figure~~ Figure 1, this material ~~is~~ includes an electrical conductor and, as may be seen on ~~figure~~ Figure 2, the block itself is a stack of layers (4) of this material, whereby these layers (4) alternate with electrical insulating layers (5~~6~~).

The stack begins with one of the layers (4) in the first face (7) of the block, through which the ionizing radiation penetrates into the block (2). The stack also terminates with one of these layers (4) in the second face (8) of the block, which is located opposite the first face (7).

In the example shown, the detector is intended to detect X-rays photons which have an energy of 5 MeV, for example.

An incident X-ray photon whose path is indicated as (9) on ~~figure~~ Figures 1 and 2 interacts with the material ~~in of~~ one of the layers (4) to produce, either by Compton effect or pair-creation effect (electron, positron), an electron with a ~~very~~ high kinetic energy, whose path is indicated by the arrow (10) on ~~figure~~ Figure 2.

Another arrow (12) has also been used to represent the path of the photon whose energy is less than that of the incoming X-Ray, ~~whereby this lower energy photon photon and which~~ results from the interaction of the X-Ray ~~latter~~ with the material.

The thickness of block 2 (counting from the first face (7) to the second face (8) of the block), indicated as E, is at least equal to 1/10 of the ~~free mean~~ free path ~~traveled by of~~ the incident X-rays photons in the conducting material. ~~It is this thickness,~~ which gives the material its high halting stopping power.

In keeping with the invention, the detector shown in ~~figure~~ Figures ~~is~~ 1 and 2 also features parallel slits (14).

In a purely illustrative but in no way limitative manner, ~~The slits of the detector is arranged shown in figure~~ Figure 1 and 2 have been laid out in such a way that the slits are

either horizontal or, on the contrary, vertical. However any other orientation is ~~this is only one possibility and other slit layouts are entirely possible,~~ depending on the intended utilization of the detector.

The slits (14) run across the block (2) from the first face to the second face thereof, thereby splitting up ~~to the~~ block into strips. The slits (14); are filled with a gas (in a manner explained later in this document), which is ionizable by the electrons resulting from the interaction of the incident ~~X-rays~~ radiation with the converting conductorive material.

~~Every electron~~ Electrons created in this fashion interacts with the gas in a slit (14) to produce positive ions, such as the ion shown by the arrow (16) and electrons, such as the electron shown by the arrow (18) ~~in figure~~ Figure 2.

It should be mentioned that the slits (14) which terminate on faces (7) and (8), are perpendicular to the faces (7) and (8).

The detector shown in ~~figure~~ Figures 1 and 2 also ~~features technology required to comprises means for createing~~ an electric field capable of extracting from block (2) the electrons resulting from gas ionization. This is done by provoking the displacement of the electrons ~~from in~~ the slits where they are first-created, towards the face (8).

~~The creation of the electric field as described above~~ This is illustrated in ~~figure~~ Figure 2 for the electron whose path bears the reference (18).

The ion corresponding to this electron is driven towards the first face (7) under the effect of the electric field.

In the example shown in ~~figure~~ Figures 1 and 2, the electric field is created by ~~polarization techniques~~ biasing means which raises the ~~voltages of the layers in the of~~ conducting material (4) to voltages which increase progressively from the first layer, located at the first block face (7) to the last layer (4), located at the second face (8).

Block (2) ~~is~~ may be placed in a hermetic enclosure (20) containing the ionizable gas. ~~However, instead of such a configuration,~~ Alternatively, the enclosure (20) ~~could~~ may ~~be provided with means~~ have the necessary technology (not shown) ~~to for~~ circulateing and purifying the gas.

The enclosure (20) ~~features~~ comprises a ~~radiolucent~~ window (22) which is transparent to the incident ionizing radiation and situated opposite the first face (7) of the block (2).

In the ~~specific~~ example shown, the window (22) is made of aluminum, ~~that is, a material radiolucent as regards~~ and transparent to the incident X- rays. However, if necessary, other materials can also be used.

The biasing means ~~polarization technology used allowing the voltages of the~~ conducting material layers (4) to be raised progressively, whereby these voltages also feature to increasing voltages comprises series-mounted electric resistors R1, R2, ... Rn (~~figure~~Figure 2).

5 It may be seen that ~~e~~Each terminal shared by 2 series-mounted adjacent resistors is connected to one of layers (4) of the conducting material, with the first terminal of the first resistor (R1) connected to the first layer (4) of the conducting material, located opposite the window (22), whereas the second terminal of the last resistor (Rn) is connected to the last layer (4) ~~on the of~~ conducting material, located ~~on at~~ the second face (8) of the block (2).

10 These ~~resistanceors~~ resistors are formed outside the enclosure (20) and connected to the layers (4) of the conducting material through electrically insulating passages (not shown) in the enclosure (20). However, the ~~resistanceors~~ resistors can also be formed inside the enclosure.

15 These resistors are formed, for example, by etching a conducting layer in, for example, gold, whereby this conducting layer is formed on an element made of an electrically ~~insulating isolating element in for example,~~ ceramic (not shown).

The respective resistor values are adjusted by ~~varying the thickness of~~ thinning this etched layer, using for this purpose, for example, laser evaporation techniques.

20 ~~This results in gradually~~ One thus obtains the increasing electric voltages, that is, a voltage gradient with the first terminal of the first ~~resistanceor~~ resistor (R1) at ground potential and the second terminal of the last ~~resistanceor~~ resistor (Rn) at a high positive voltage.

The detector shown in ~~figure~~Figures 1 and 2 also features ~~the necessary technology to~~ comprises means for analyzing the electrons extracted from block (2) via the electric field, and which leave block (2) by the second face (8).

25 This electron analysis ~~technology also means~~ includes an avalanche gas amplifier (24) capable of producing electron avalanches from the electrons extracted from the block (2).

As may be seen from ~~figure~~Figure 2, this amplifier (24) has 2 electrically conducting ~~grills-grids~~ (26 & 28) which are placed in the enclosure (20), at in front of the second face (8) of block (2) and which are parallel both to each other and to this second face (8).

30 The first ~~grill-grid~~, that is, the one nearest the second face (8) is raised up to a positive voltage, superior to greater than the voltage applied to the second terminal of the last resistor (Rn), and the second ~~grill-grid~~ (28) is raised up to a positive voltage, superior to greater than the voltage applied to the first ~~grill-grid~~ (26).

In the example shown, the first and second ~~grills-grids~~ are raised up to a voltage of 10 kV and 16 kV respectively, whereas the layer (4) nearest the window (7) is ~~earthed-grounded~~ and the layer (4) nearest the ~~grill-grid~~ (26) is raised to a voltage of 8kV.

Other types of ~~electron have-lunch-avalanche~~ amplifiers can also be used; for example PPAC, "Micromegas" (see documents [4] and [5]) or GEM type avalanche amplifiers.

Attention is drawn to the fact that ~~and-the~~ ionizable gas is a mixture of:

- a gas, ~~for example, e.g.~~ Argon, allowing for the multiplication, by avalanche, of electron extracted from block 2,
- a gas, ~~for example, e.g.~~ dimethyl ether, or DME, allowing for the avalanche amplification coefficient to be controlled, and
- a gas or vapor, ~~for example, e.g.~~ triethylamine or TEA, capable of scintillation ~~from under the effect of~~ the electron flow in the avalanche.

~~One possibility of such a mixture, by no means the only such possibility, is~~ In a purely illustrative and in no way limitative manner, a mixture consisting of 86% Argon, 2012% DME, and 2% TEA is used.

Examples of avalanche gas amplifiers are given in the documents [4] and [5].

Every electron leaving the block (2) via the second face (8) of the block (2) is successively accelerated by the conducting ~~grills-grids~~ (26 & 28), thereby creating an electron avalanche (29), concentrated essentially between these two ~~grills-grids~~.

Moreover, this avalanche ~~results in~~ generates an ultraviolet radiation (30) by interaction with the TEA.

The enclosure (20), opposite the second ~~grill-grid~~ (28), comprises ~~features~~ a window (32) which is ~~radiolucent-transparent~~ with respect to this ultraviolet radiation (made out of quartz, for example).

Outside the enclosure (20), opposite this quartz window (32), a camera (34) capable of detecting the ultraviolet radiation (30) is fitted.

Naturally, if the chosen gas mixture gives off visible radiation by interaction with the electron avalanche, then the camera chosen must be capable of detecting ~~this visible such a~~ radiation and the ~~material used in the~~ window (32) must be ~~radiolucent-transparent~~ with respect to this radiation.

Moreover, instead of using a camera, a matrix of amorphous silicon photodiodes (not shown) may also be used to detect the visible or ultraviolet radiation resulting from the interaction of the gas mixture with the electron avalanches.

In this case, the matrix is affixed against ~~grill-grid~~ (28), which increases compactness and reduces weight.

Parasitic reflections of visible or ultraviolet light can be avoided by, for example, oxidizing the appropriate metal, and so blacking out the face of the layer (4) located opposite the ~~grill-grid~~ (26).

The block (2) shown in ~~figure~~Figures 1 and 2 can be replaced by the block (36), whose perspective is schematically represented in ~~figure~~Figure 3.

In the case of ~~figure~~Figure 3, an electrically ~~isolating~~insulating material (for example, ceramic, glass, or plastic material), or a highly resistive material (for example, ceramic material or oxide (~~resistance~~having a resistivity of at least equal to $10^5 \Omega \cdot \text{cm}$) is used where block (36) is a stack of layers (37) of this material, or can alternatively, be made from ~~one single mass of this material in the bulk state.~~

In the case of ~~figure~~Figure 3, block (36) also ~~features~~comprises a first conducting layer (38) and a second conducting layer (40) formed respectively, ~~on~~at the first face and the second face of block (36).

The conducting layers (38 & 40) can be replaced by conducting ~~grills~~ grids.

Figure 3 also shows the parallel slits (14) running across the block (36), which are perpendicular to the first and second block faces. These slits divide the block into strips.

In this case, the electric field is generated by using ~~technology means~~ (not shown) capable of raising the second conducting layer (40) to a high positive voltage, ~~whereby~~ whereas the first conducting layer (38) is grounded.

~~One possible configuration, but by no means the only possibility, is:~~ In a purely illustrative but in no way limitative manner, layers (4) are in tungsten and layers (6) are in ~~kaptan~~ KAPTON (trademark) or other plastic or plastic-like strip, the distance between the second face (8) and the first ~~grill-grid~~ (26) is 1.5 mm and the distance between the two ~~grills~~ grid (26 & 28) equals 3 mm, the thickness of block (2) or block (36) is 30 mm, the thickness of the conducting layers (4) is 250 μm , the thickness of the ~~isolating~~insulating layers (6) is between 50 μm ~~to~~ and 500 μm , the thickness of the conducting layers (38 & 40) is 10 μm , these conducting layers (38 & 40) are in copper, the width of the slits (14) is 500 μm , their length (L) varies from 10 cm to 50 cm and these slits are separated from each other by about 700 μm .

Instead of tungsten, lead or depleted uranium (~~uranium-235~~) could also be used to form layers (4).

Instead of being perpendicular to the first face (7) of block (2) or block (36), the slits (14) or, more precisely, the slits' planes, that is, the mid-perpendicular planes of the slits, which extend ~~more or less depending on~~ along the length of the slits (14) - ~~and have a trace~~ shown as (X) in the section plane of ~~Figure~~ Figure 4, - ~~can create an angle α of between~~ 1 ° and 5 ° with a plane (whose trace is shown as Y), which is perpendicular to this first face (7) as illustrated in ~~figure~~ Figure 4.

This has the advantage of increasing the stopping power ~~applied to~~ with respect to the incident ionizing radiation, subject to the detector being ~~turned~~ positioned in such a way that the incoming radiation arrives at face (7) of block (2) or block (36), and in a direction perpendicular to the layers (4) or (38).

Moreover, it should be noted that the thickness of blocks (2) and (36) is chosen on the basis of the desired stopping power.

Moreover, the dimensions of the slits (14) and the layers in blocks (2) or (36) are chosen to optimize the spatial resolution of the corresponding detector, and the performance level of this detector, ~~that is, the quantity of~~ for collecting the electrons generated in the slits.

It should be noted that, under the previous state-of-the-art, the total thickness of the metal plates (~~cumulative total with~~ thickness counted parallel to the incident ionizing radiation) was chosen so as to make metal plate etching possible.

In the detector of ~~figure~~ Figures 1 and 2, and, likewise in ~~the detector of Figure~~ Figure 3, the total thickness of the layers in blocks (2) or (36) is entirely determined by ~~operating~~ limitations for implementing ~~imposed by~~ the electric field (or more precisely, the electrostatic field).

These layers can be very thin or, on the contrary, very thick since, ~~in both cases,~~ slits can still be used machined.

Using ~~slits such as described in this document~~ in accordance with the present invention, instead of holes, dramatically improves the detector's performance level (~~that is, quantity of electrons generated in the slits~~) but also, ~~and more surprisingly,~~ which is unexpected, the spatial resolution of the detector.

Indeed considering the example of ~~As shown by figure~~ Figure 2, the spatial resolution along the direction D-1 perpendicular to slits (14) is determined by the gap between these slits, and ~~although electrons do drift inside the slits along a direction D2 (perpendicular to D1),~~ the spatial resolution does not limit the scattering of the electrons which drift in the slits, but experiments show that this electron ~~drift~~ scattering is not very ~~considerable;~~ important and in fact, has a the width of the probability distribution for this drift whose width at mid-

~~height half maximum~~ is less than the gap between the slits (14) with a slit gap equal to, for example, $500\text{ }\mu\text{m} + 700\text{ }\mu\text{m} = 1.2\text{ mm}$.

Figure 5 represents a schematic perspective view of another detector designed in accordance with the present invention.

5 In the case of ~~figure~~Figure 5, the detector ~~features~~comprises a block (42) which consists of a stack of strips (44) made from an ~~isolating~~insulating (or highly resistive) converting material, for example, in ceramic or plastic, whereby the strips are separated from each other by lower spacers (46) and upper spacers (48).

These spacers are made of plastic, for example.

10 The spacers allow the slits (14) to be created between the strips, whereby ~~the boundaries of each slit (14) are created~~is delimited by two adjacent plates, one lower spacer (46) and one upper spacer (48).

As was previously the case, the slits (14) are filled with ~~an ionizable~~a fluid, medium ~~which is ionized~~able by the particles released during the interaction of the incident ionizing radiation with the strips (44).

15 The block (42) also ~~features~~comprises a first conducting layer (49) and the second conducting layer (50) formed, respectively, ~~on~~at the first face and the second face of the block to create an electric field by raising the first layer (49) to a first electric voltage and the second layer (50) to a second voltage which is greater than the first voltage, whereby the resulting electric field ~~is used~~makes it possible to extract the electrons created by ionization from block (42).

As was also the case in ~~figure~~Figure 3, one can replace the layers (49) and (50) by two electrically conducting ~~grills~~grids, one at the first block face, and the other at the second block face.

25 As may be seen on ~~figure~~Figure 5, the layers ~~(or grids)~~ (49) and (50) ~~—or the grills—~~ have slits, such as slits (51), respectively located opposite slits (14) and ~~thereby~~ extending slits (14).

We shall now give some examples of manufacturing procedures for a detector designed in accordance with the precepts of the current invention.

30 If the block consists of alternating conducting/~~isolating~~insulating layers, one begins by ~~putting~~fixing these layers ~~against~~to each other, by gluing them together, for example.

If the block is made from ~~one single mass of this~~a bulk insulating material, one begins by attaching the two conducting layers to the first and second faces, respectively, of ~~this single isolating mass~~bulk block, by gluing them together, for example.

Once the block has been created, the slits are then formed by, for example, waterjet cutting, electrical discharge machining or roll-out stretch wire.

It should be specified that gluing has the advantage, especially in the case of waterjet cutting, of preventing accidental dispersion of the waterjet between the layers during the cutting.

Before creating a slit, a guide-hole may be ~~created in~~ formed through the block, which will be used as a basis to create the slit using, for example, a waterjet applied through a nozzle, which is moved around with respect to the block.

~~Guide~~ Such a holes, which can be formed by, for example, chemical etching or ~~some~~ any other technique, present the advantage of avoiding frontal shock when the waterjet is first turned on.

However, such ~~guide~~-holes are not necessary if the material used for forming ~~in~~ the block does not crack.

Creating the slits is therefore a very rapid process.

As an ionizable fluid medium, ~~instead of using an ionizable gas,~~ one can also use a liquid, for example, Xe, or a supercritical phase such as CO₂, for example, (in supercritical phase).

Figure 6 schematically illustrates a variation of ~~figure~~ Figure 32. The detector in ~~figure~~ Figure 6 ~~features~~ comprises a supplementary ~~isolating~~ insulating layer (6) formed on the last layer (4) located ~~on~~ at the second face (8) of block (2) and an electrically conducting layer (4a) formed on this supplementary layer (6). The layer (4a) (through which slits (14) run, as is also the case for the adjacent layer (6)) is made of an absorbing electrical conducting material, whose role is to absorb the secondary particles created in the last layer (4), whereby the objective is to improve spatial resolution by preventing the secondary particles from directly penetrating into the avalanche gas amplifications over at a large angle (which would create blur).

The detector, subject of the present invention, may be used, for example, for positron emission tomographic applications ~~via positron emission~~ (PET scanner with an incident energy of about 0.5 MeV) or in radiotherapy with energies of about 1 MeV. If the incident radiation is made up of X-ray photons, the detector may be used in all situations where the photoelectric effect is negligible compared to the other types of interaction (for example, Compton effect or pair-creation effect).

The documents mentioned in the present description are:

[1] V. Perez-Mendez, S.I. Parker, IEEE Trans. Nucl. Sci. NS-21 (1974) 45

- [2] S.N. Kaplan, L. Kaufman, V. Perez-Mendez, K. Valentine, Nuclear Instruments and Methods 106 (1973) 397
- [3] AP Jeavons, G. Charpak, RJ Stubbs NIM 124 (1975) 491-503
- [4] FR 2739941 A, "Décteur de position, à haute résolution, de hauts flux de particules ionisantes". Invented by G. Charpak, I. Giomatrix, Ph. Rebourgeard and J.P. Robert - See also international application WO 97/14173
- [5] FR 2762096 A, "Décteur de particules à électrodes parallèles multiples et procédé de fabrication de ce détecteur". Invented by G. Charpak, I. Giomatrix, Ph. Rebourgeard and J. P. Robert - See also EP 0872874 A
- [6] J.L. Gerstenmayer, D. Lebrun, and C. Hennion, "Multistep Parallel Plate Avalanche Chamber as a 2D imager for MeV pulsed radiography". SPIE Proceedings, vol. 2859, pages 107 to 114, SPIE symposium, 7-8 August 1996, Denver, Colorado
- [7] J.L. Gerstenmayer, "High DQE performance X- and Gamma-ray fast imagers : emergent concepts", 1998 Symposium on Radiation Detection and Measurement, Ann Arbor, Michigan, 11 - 14 May 1998, Proceedings in Nuclear and Methods in Physics Research A.